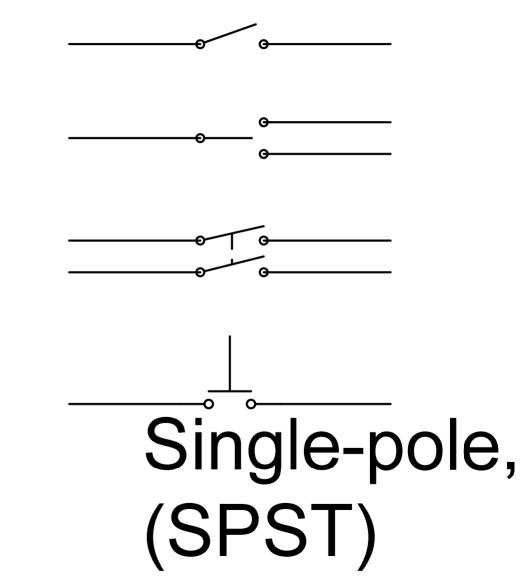
2.996/6.971 Biomedical Devices Design Laboratory

Lecture 10: Sensors

Instructor: Dr. Hong Ma October 22, 2007

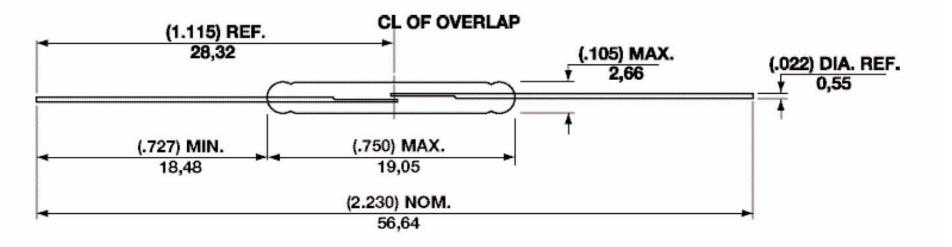
Switches



- Pull-ups and pull-down
- De-bouncing

Reed Switches

- Magnetically operated
- Non-contact operation
- Door open/close detection



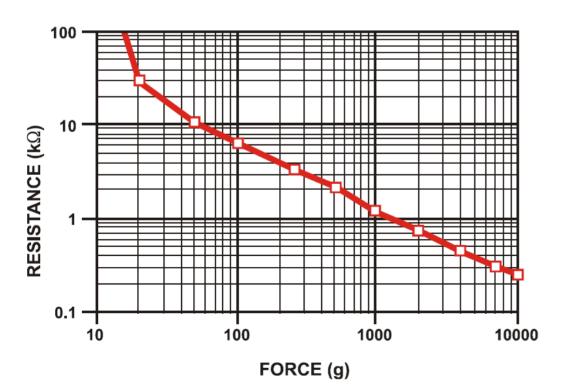
Piezoresistive Strain Gages

$$\frac{dR}{R} = \frac{dl}{l} \left(1 + 2\upsilon + C(1 - 2\upsilon) \right) = G\frac{dl}{l} = G\varepsilon$$

- Gage factor
 - Common metals G~2-3
 - Platinum G=6
 - Semiconductors G~40-200
- Metals have greater elongation limits
 - Constantan foil:
 - Up to 3-5% elongation
 - G=2
 - Higher strains are limited by bonding

Force Sensitive Resistors (FSR)

- Pressure sensitive polymer
 - Decrease in resistance with applied pressure
- Not suitable for precision measurements!
 - Force accurace range from ±5 to ±25%
- Repeatable mechanics is key!

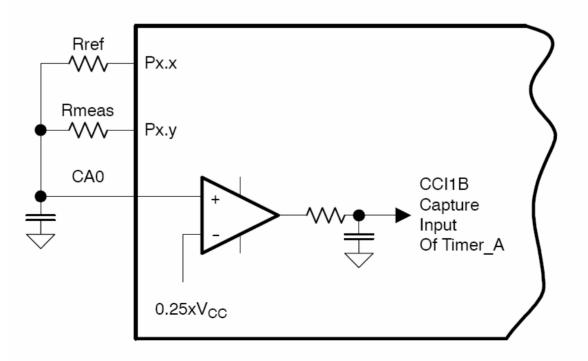


Photoresistor (Light-Dependent Resistor)

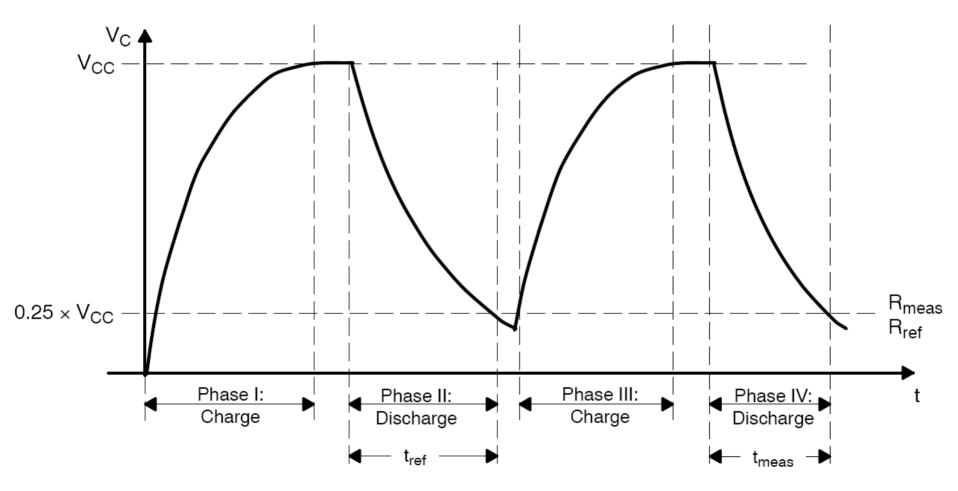
- Very slow (response time ~100ms)
- Hysteresis behavior
- CdS ~ 480nm
- ZnS ~ 320nm
- CdSe ~ 720nm
- PbS ~ 2000nm

Resistance Measurement Circuits

- Quick-and-dirty techniques:
 - Trans-impedance amplifier
 - Resistive divider
 - Timer-comparator

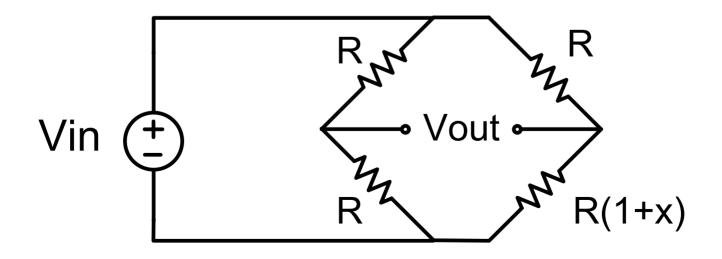


Result only dependent on the ratios of the test and reference resistors

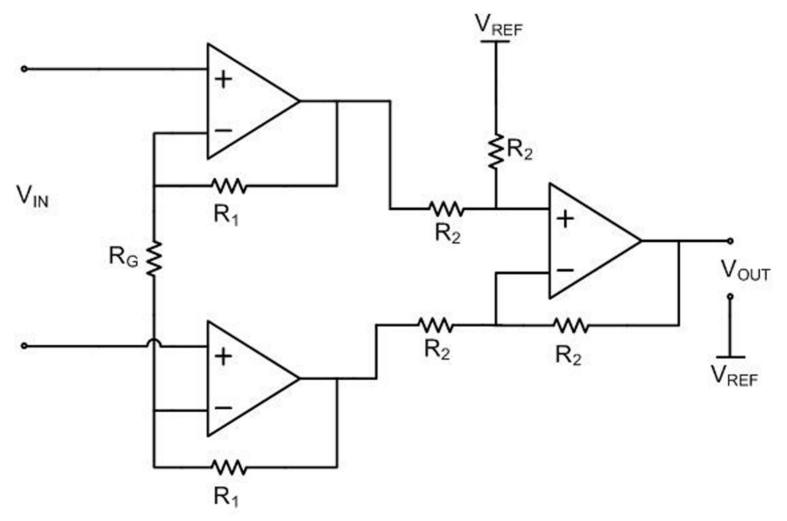


Wheatstone Bridge

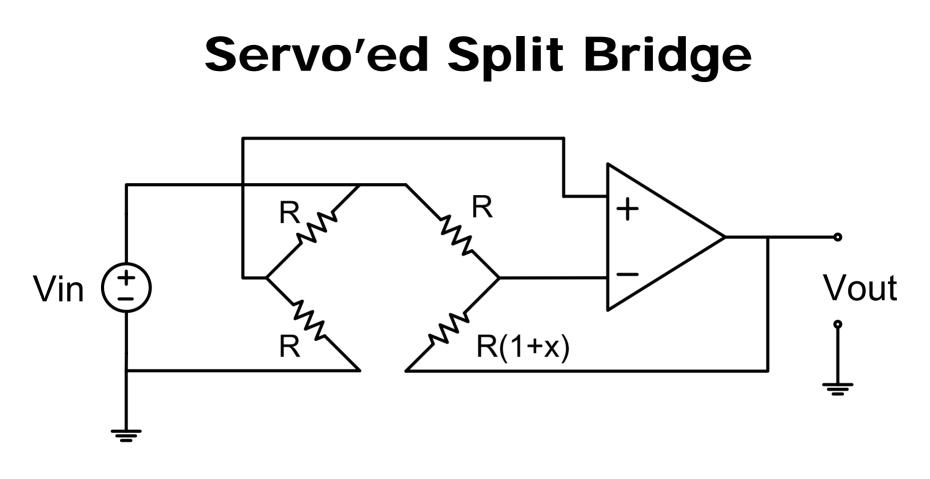
- Match resistors to remove common-mode interference
- Not linear
- Linearize using multiple sensors



Instrumentation Amplifier



- Available as a packaged amplifier, e.g. INA118
- R_G and V_{REF} accessible externally

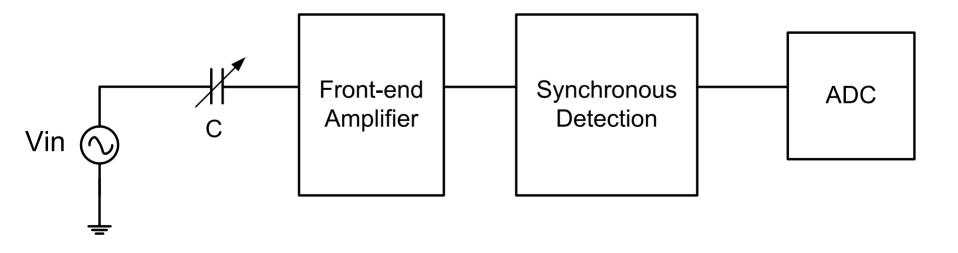


- Vout = $-x^*$ Vin/2
- Require dual supplies if x>0

Capacitance (E-field) Sensing

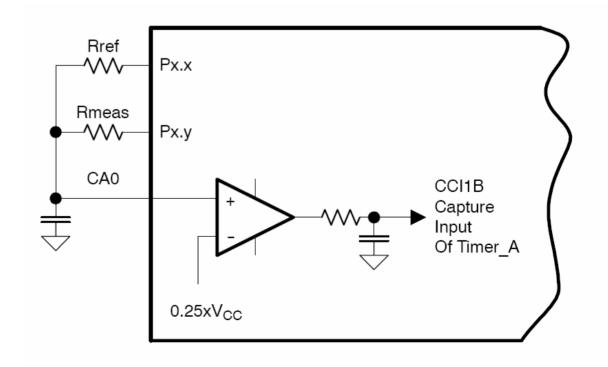
• Cost effective

- Infinite resolution
- Require transient excitation signal

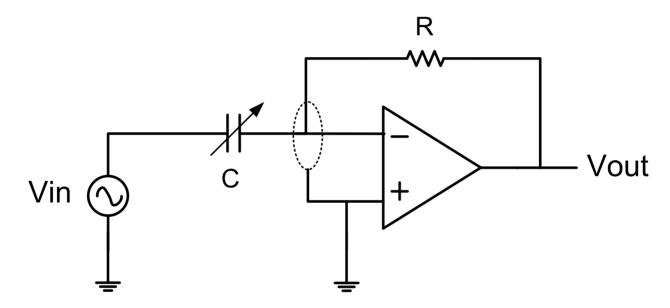


Cap Sensing - The quick and dirty way

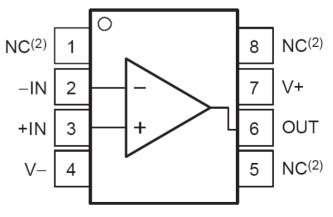
- Exchange the resistor and capacitor
- Measure capacitor discharge time



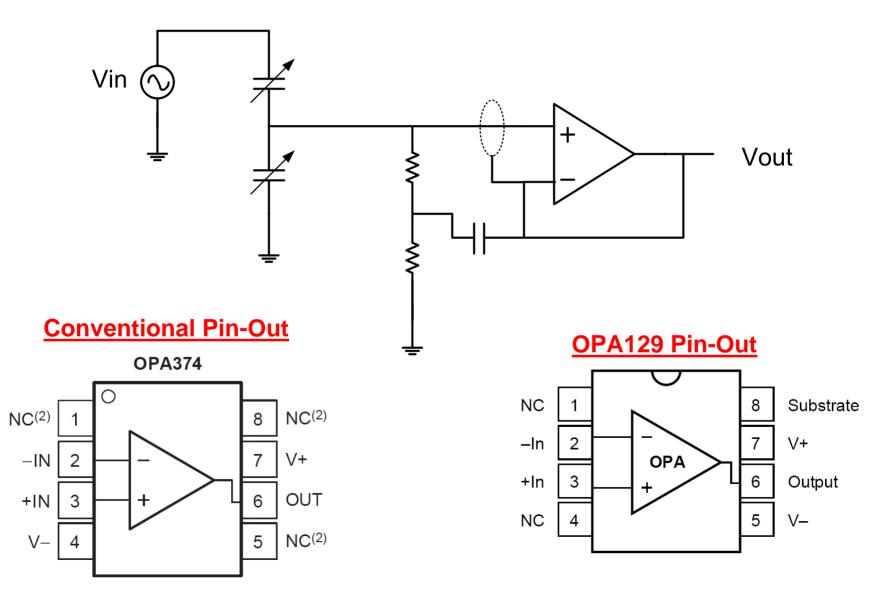
Low-Impedance Method



OPA374



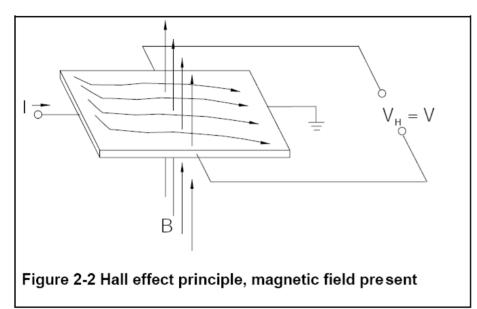
High-Impedance Method

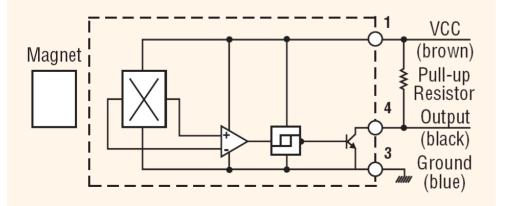


Magnetic Field Sensing

- H-field
 - Applied field
 - Units (CGS): Oe (Oersted)
 - Units (SI): Ampere Turns / Meter
- B-field
 - Applied + induced field
 - $B = \mu(H + M)$
 - Units (CGS): Gauss
 - Units (SI): Tesla (1 Tesla = 10^4 Gauss)
- In air (in CGS units): 1 Oe = 1 Gauss
- Earth's magnetic field: 0.3 0.6 Gauss
- Sensitivities:
 - Hall-effect: >50 Oe
 - GMR: 0.1 to 0.5 Oe

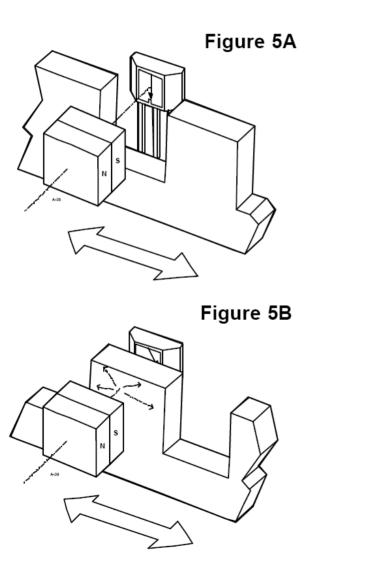
Hall-effect Sensors

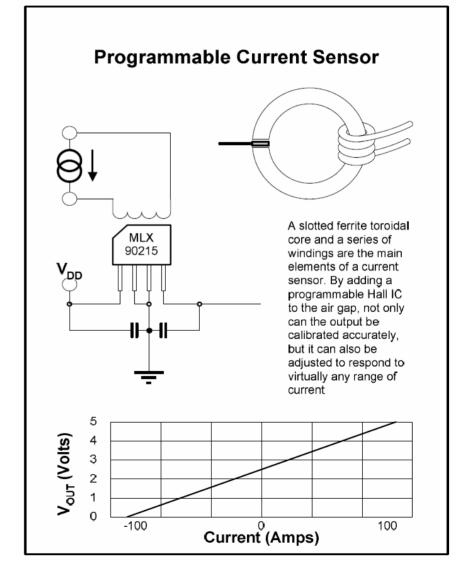




- Ubiquitous
- Low cost
- Non-contact
- Line-of-sight not required
- Poor accuracy
 - >50 Oe magnetic field required
- Generally used in switch mode

Applications of Magnetic Sensors

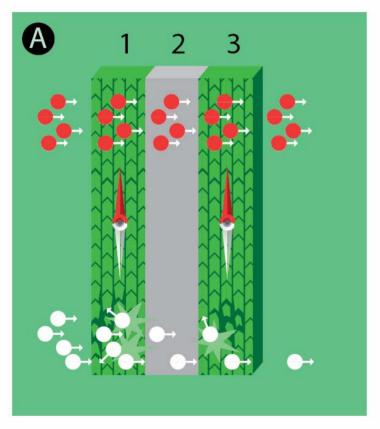


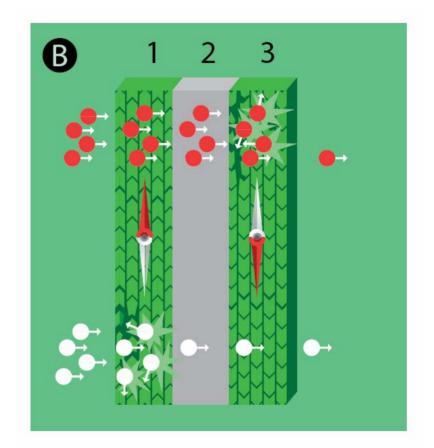


Giant Magnetoresistance (GMR)

- Nobel Prize in Physics 2007
- Discovered in 1988, brought to market in 1997
- Albert Fert (France) and Peter Grünberg (Germany)

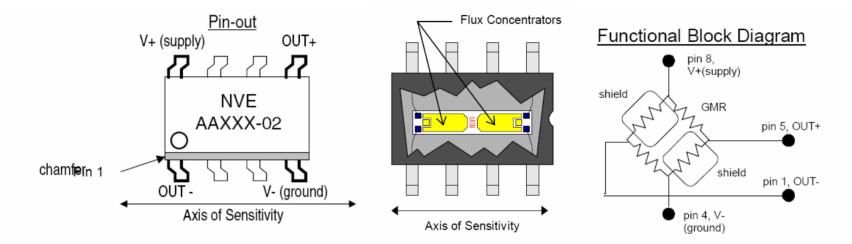
Spin-Dependent Conduction





- ~5nm layers
- Section 2 could be a conductor or insulator
- Practically 8 12% conductivity change

GMR Sensors from NVE



Magnetic Characteristics:

Part Number	Saturation Field (Oe¹)	Linear Range (lOe¹l)		Sensitivity (mV/V-Oe¹)		Resistance (Ohms)	Package ²	Die Size³ (μm)
		Min	Max	Min	Max			
AA002-02	15	1.5	10.5	3.0	4.2	5K ±20%	SOIC8	436x3370
AA003-02	20	2.0	14	2	3.2	5K ±20%	SOIC8	436x3370
AA004-00	50	5	35	0.9	1.3	5K ±20%	MSOP8	411x1458
AA004-02	50	5	35	0.9	1.3	5K ±20%	SOIC8	411x1458
AA005-02	100	10	70	0.45	0.65	5K ±20%	SOIC8	411x1458
AA006-00	50	5	35	0.9	1.3	30K ±20%	MSOP8	836x1986
AA006-02	50	5	35	0.9	1.3	30K ±20%	SOIC8	836x1986

Hysteresis and Biasing

• All magnetic materials exhibit hysteresis behavior

